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ELECTROCHEMICAL IMPREGNATION OF NICKEL COMPOSITE  
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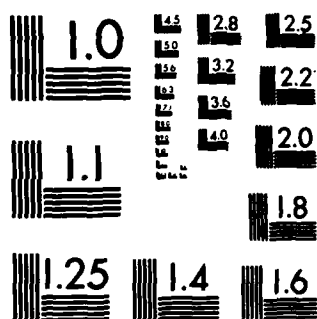
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## ELECTROCHEMICAL IMPREGNATION OF NICKEL COMPOSITE ELECTRODES

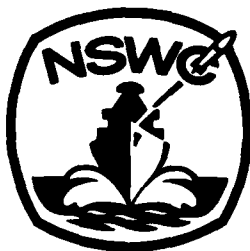
BY A. L. LEE W. A. FERRANDO F. P. FLIGHT

RESEARCH AND TECHNOLOGY DEPARTMENT

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The nickel composite electrode is made by coating mats of graphite fiber with electroless nickel. A nickel coated mat is much lighter when used in an electrode than the customary nickel powder for a given material volume. A nickel wire grid is sandwiched between several such mats and sintered under compression to the desired thickness.

While maintaining sufficient electrical conductivity, the resulting plaque is lightweight, durable and highly porous. Variation of compaction pressure or graphite fiber content produces porosity in the range of 60% to 90%. The open composite plaque pore structure allows easy active material deposition.

The nickel hydroxide active material was loaded into the electrode plaque by electrochemical impregnation. An ethanol-based nitrate impregnating solution was employed. Optimum impregnations were achieved using a constant current density of 0.058 amperes/cm<sup>2</sup> (0.374 amps/in<sup>2</sup>) of electrode surface.

Composite electrodes fabricated for this study routinely achieved energy densities of 170 amp hours/kilogram (Ah/Kg) at a C/2 discharge rate to 0.5 V. cutoff. Use of the composite electrode in Ni-Cd cells will increase their gravimetric energy density 40% above available commercial cells.

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## FOREWORD

The objective of this study was to explore the application of the electrochemical impregnation technique to the nickel composite electrode (Ni.C.E.). The impregnating conditions examined include current density, current frequency, and loading level. In addition, various electrode characteristics which affect performance were studied. These characteristics were thickness, porosity, and resistivity.

Performance of the nickel composite electrode was determined to be superior to that of commercially available powder sintered electrodes on a gravimetric basis. Ni.C.E. achieves energy densities over 170 Ah/Kg at C/2 discharge rates. The active material utilization exceeded 100 percent. Commercial powder sintered electrodes, by comparison, achieve about 110 Ah/Kg. Volumetric energy densities at present are comparable for Ni.C.E. and commercial sinters.

The most efficient impregnation and best morphology of active material, fine black crystals, was obtained using a direct current density of 0.058 amperes/cm<sup>2</sup> (0.374 amps/in<sup>2</sup>).

Eighty-one percent void volume and 40 mil (1 mm) thickness were the optimal composite plaque substrate characteristics, as determined by comparing energy density and active material utilization of the finished electrodes in cycling tests.

Approved by:

*J. R. Dixon*  
JACK R. DIXON, Head  
Materials Division



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## INTRODUCTION

The nickel electrode is the backbone of an entire class of alkaline secondary cells including the Ni-Cd, Ni-Fe, Ni-Zn and Ni-H<sub>2</sub> systems. The most successful nickel electrode for many purposes has been the sintered type. Sintered nickel electrodes have been made conventionally for many years from fine nickel powders. While these electrodes have amply proven themselves in many applications, there continues to remain a need for improved energy density at reduced fabrication costs.

The nickel composite electrode<sup>1</sup> (Ni.C.E.) has been under development at NSWC for several years. The composite substrate was fabricated by electroless nickel coating<sup>2</sup> graphite mat fiber material and sintering under compaction pressure. While maintaining sufficient electrical conductivity, the resulting plaque is lightweight, durable and highly porous (55 to > 90 percent). The active material, nickel hydroxide was loaded into the plaque by an electro-chemical impregnation method developed and reduced to practice by Pickett.<sup>3</sup>

In order to produce a successful electrode, each step of the fabrication operation must be understood and each parameter must be carefully controlled. The general objectives of this report are the documentation of the major fabrication processing steps and preliminary study of several important parameters. In particular, the nickel coating procedure is described in some detail. Impregnation current density, frequency of applied current and active material loading level, each controllable in the impregnation phase, are examined for their contribution to electrode utilization. Finally, the effects of various plaque parameters: thickness, porosity and resistivity on electrode performance are studied by means of extensive cycling tests.

## EXPERIMENTAL METHOD

Each graphite mat was uniformly coated with nickel prior to compression and sintering. After initial cutting and weighing, the mat was soaked in hot (100°C) deionized water. Care was taken to ensure that the mat remained undamaged and free of clinging air bubbles. The surface was cleaned by immersion in dilute hydrochloric acid. After soaking for 5 minutes in the dilute hydrochloric acid, the mat was transferred directly to the catalyst solution for a similar period. In each of these soaking operations, the mat was

compressed gently in order to allow the solution to penetrate the fibers completely. The catalyst provides sites which promote precipitation of nickel from the coating solution [catalyst, accelerator, electroless nickel solutions from Allied-Kelite Division, Richard Chemical Co.]. After double rinse in deionized water, the mat was immersed in an accelerator solution (50-65°C) for 5 minutes and again rinsed twice in deionized water. For each mat, 600 ml of the nickel coating solution were used. This amount is sufficient to produce a 0.5 $\mu$  coating on a 1 gram mat for an immersion time of about 1 hour. Often, this step must be repeated in order to obtain coating thickness between 0.6 and 0.8 $\mu$ . Optimal coating bath temperature was found to be 80 to 84°C.

After incorporating several flipping and compressing techniques, an optimal method for ensuring complete coating was developed. By leaving the mats on the surface of the solution and flipping them periodically (once every 2 minutes), a uniform nickel coating was achieved. If the mats are constantly compressed and flipped and forced to remain submerged, the reaction rate is accelerated to an unacceptable level. The solution eventually turns gray and nickel is coated onto the container. It is believed that small slivers of carbon thrown off the mat during aggressive flipping and compression act as nucleation sights for the reaction, in turn causing a runaway situation.

Upon completion of the coating process, the mats were removed from the expended solution. After a double rinse in deionized water and an acetone rinse, they were allowed to air dry for a period of 1 to 2 hours. Completely dry nickel coated mats appear grayish silver in color and provide a lightweight, compressible and sinterable substrate. Occasionally a mat will display light brown patches, however, this does not seem to affect the sintering process or the performance of the plaque. It is very important that the mats be completely and evenly coated and that no small uncoated spots remain. If the mats have uncoated spots, the final sinter will be weak and blister prone.

In order to obtain a properly conducting substrate, 0.6 to 0.8 $\mu$  (1 $\mu$  = 10<sup>-6</sup> meters) of nickel must be deposited on the fibers. This can be equated roughly to a final (after coating) mat weight of about three times its initial weight. The sintering process itself and measurements on the Ni.C.E. plaques for porosity, resistivity and tensile strength have been reported previously.<sup>4</sup> A wide range of porosity (55 to 90 percent) is achievable by varying the fiber density. The open pore structure of the composite allows efficient impregnation of the active material.

#### PARAMETERS AND CONDITONS OF DATA ACQUISITION

Data was acquired in two stages. In stage one, three impregnating conditions, current frequency, current density, and loading level were chosen as variables. A statistical method of analysis, the Box Behnken Plan,<sup>5</sup> was used to evaluate the results. In stage two, the best conditions resulting from the Box Behnken Plan were used to study additional parameters--thickness, porosity, and resistivity, which affect performance of the electrode.

### IMPREGNATION OF THE ELECTRODE PLAQUE

A schematic of the electrochemical impregnation process is shown in Figure 1. The process consists of impregnation and then formation of the electrode plaque. Figure 2 shows the impregnation cell with plaque and nickel counter-electrodes (anodes) in place. This cell is immersed in the impregnation bath.

The impregnation conditions examined are listed in Table 1. Three trials were made for each condition.

TABLE 1. IMPREGNATION CONDITIONS

| <u>Current Frequency</u> | <u>Current Density</u>     | <u>Loading Level</u> |
|--------------------------|----------------------------|----------------------|
| direct current           | 0.106 amps/cm <sup>2</sup> | 2.0 grams            |
| 0.33 pulses/sec          | 0.058 amps/cm <sup>2</sup> | 1.5 grams            |
| 10 pulses/sec            | .029 amps/cm <sup>2</sup>  | 1.0 grams            |

Electrodes were impregnated using a combination of the three above conditions.

The electrode plaque (dimensions 2 3/4" x 1 3/4") acted as a cathode in the center slot of the impregnating cell (see Figure 2) between consumable nickel anodes.

The impregnating solution consisted of 1.8 M (93 wt/o) nickel nitrate ( $\text{Ni}(\text{NO}_3)_2$ ) and 0.135 M (7 wt/o) cobalt nitrate ( $\text{Co}(\text{NO}_3)_2$ ) in a 50-50 ethanol-water mixture. Control of the solution pH around 2.5 was found to be very important. This fact will be discussed later. Solution temperature was maintained between 75° and 80°C.

### FORMATION OF ELECTRODE

Following impregnation, the plates were formed. The formation process reduces residual nitrates into ammonia and cleans the surface of the electrode. It also appears to redistribute the active material by helping to unblock small pores. The electrolyte was 20 percent KOH. The formation consisted of: (1) a 20 minute cathodization period and (2) polarity reversal (anodization) for another 20 minutes. This process was repeated three times. The current applied for each period is indicated in Table 2. For some trials, the initial cathodization period was extended to 2 hours.

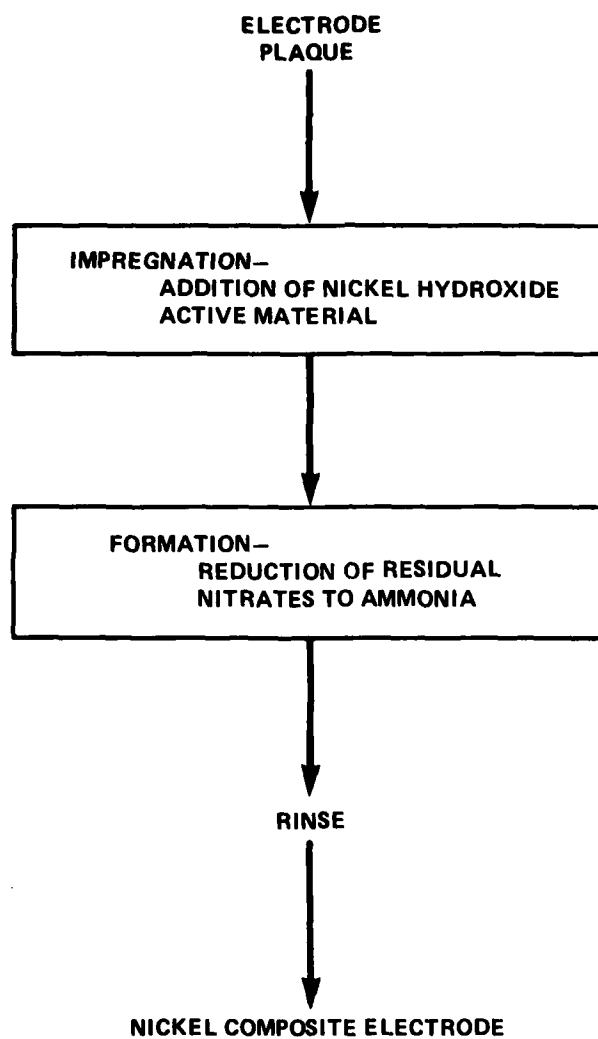


FIGURE 1. THE ELECTROCHEMICAL IMPREGNATION PROCESS

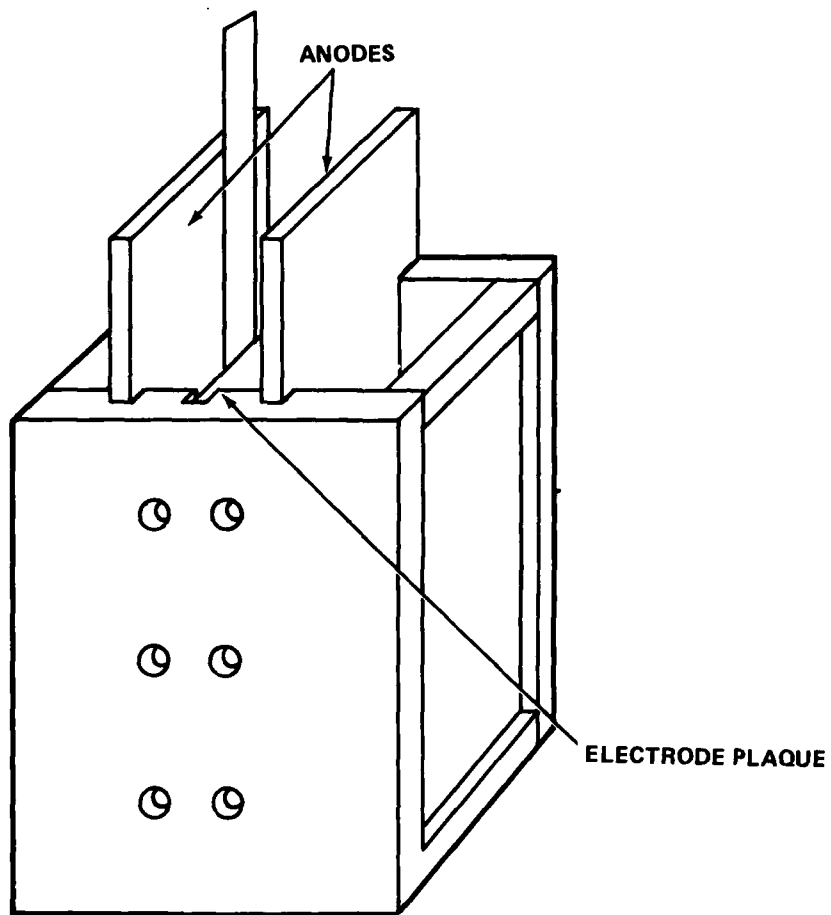


FIGURE 2. IMPREGNATION CELL

TABLE 2. ELECTRODE FORMATION PROCESS IN 20 PERCENT KOH SOLUTION

| Cycle   | 1                            | 2                            | 3                            | 4                            |
|---------|------------------------------|------------------------------|------------------------------|------------------------------|
| Applied | 0.070 amps/cm <sup>2</sup>   | 0.070 amps/cm <sup>2</sup>   | 0.0155 amps/cm <sup>2</sup>  | 0.0109 amps/cm <sup>2</sup>  |
| Current | (0.45 amps/in <sup>2</sup> ) | (0.45 amps/in <sup>2</sup> ) | (0.10 amps/in <sup>2</sup> ) | (0.07 amps/in <sup>2</sup> ) |

After formation, the electrodes were thoroughly rinsed in circulating deionized water. Each electrode was dried and weighed. The C rate was determined from the dry active material weight in the electrode using the electrochemical equivalent for nickel of .289 Ah/gram.

#### TESTING OF ELECTRODE

A single impregnated composite electrode was sandwiched between commercial cadmium negatives. The number of negatives was chosen to provide a positive limiting condition. Each positive was wrapped in a single layer of nylon and permion [Permion Division, RAI Research Corp., Hauppauge, L.I., N.Y.]. The stack was inserted into a chemically resistant plastic case containing 32 percent KOH electrolyte with no additives, under flooded conditions. The continuous test regime included discharge (DOD 95 percent) at the C and C/2 rates, respectively, performed by automatic cycling devices in a constant current mode. Charging was carried out at the C rate in all cases.

#### DATA AND RESULTS

##### Part I

Impregnating conditions of current frequency, current density, and loading level were studied. The three variables were examined by the Box Behnken Plan. This statistical method of analysis allowed three independent variables to be studied by plotting middle-of-the-edge points. This method minimized the number of trials required for statistical confidence. The trials were plotted according to the Box Behnken Plan on a three dimensional graph (see Figure 3). Variables of current frequency, current density, and loading level are plotted along the X, Y, and Z axes respectively. Active material utilization to .5 volts and .9 volts discharge cutoff respectively are indicated.

From the Box Behnken test, active material utilization results indicated that the best impregnating condition was a direct current density of 0.058 amps/cm<sup>2</sup> and high loading levels, 1.5 to 2.0 grams. Active material utilization in the direct current trials was higher than that at .33 pulses/sec. There was

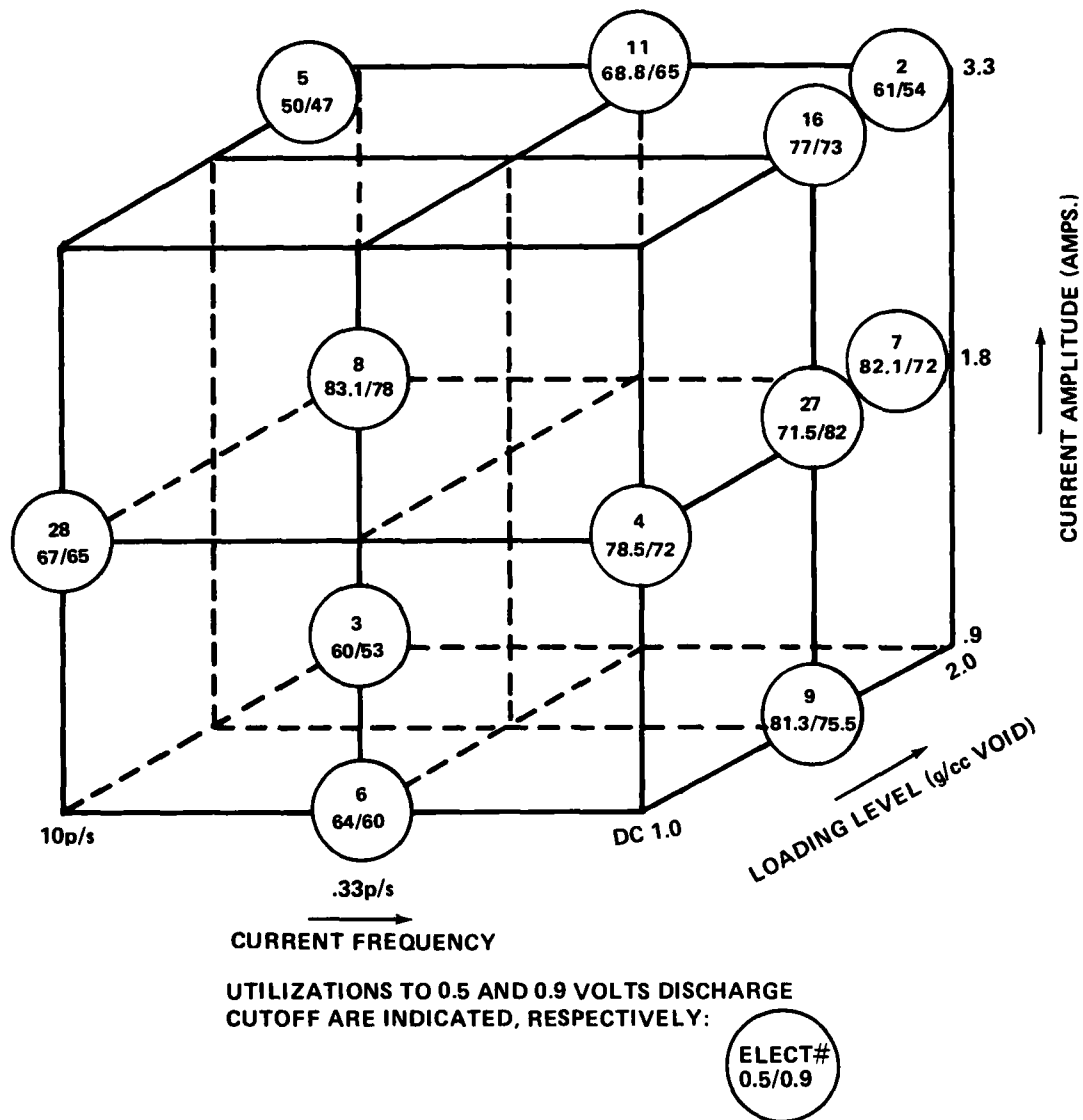


FIGURE 3. BOX BEHNKEN PLAN IMPREGNATION TRIALS

no significant difference in utilization between direct current and 10 pulses/second. Having made these observations on the relative efficiency of pulsed current, direct current was the optimal choice for current frequency.

Current density of 0.058 amps/cm<sup>2</sup> resulted in the best form of active material. The low current, 0.029 amps/cm<sup>2</sup>, was observed to plate nickel onto the electrode plaque. High current, 0.106 amps/cm<sup>2</sup>, loaded the plaque with green hydrated form of nickel hydroxide. The best current density of 0.058 amps/cm<sup>2</sup> resulted in black, evenly distributed active material.

High plaque loading levels were found to be desirable because of the measured higher energy densities.

## Part II

Part II of the experiment involved studying the effects of electrode physical characteristics--thickness, porosity, and resistivity on performance by using the current settings determined from Part I. Individual parameters were evaluated by studying the cycling tests data, comparing utilizations and energy densities.

From the cycling test data, the performance and quality of the electrode were evaluated. Data on electrode #41 is shown at 50 cycle intervals in Figure 4. The set of curves shows the changes in charge-discharge profile shape as the composite electrode is cycled.

Utilization at .5 volts and .9 volts discharge cutoff were calculated from the cycling test data and plotted. Figure 5 displays the utilization curve of electrode #41, active material utilization versus number of cycles. The corresponding energy density is indicated along the right edge of the graph. The utilization curve of electrode #46 is shown in Figure 6. The respective electrode characteristics and impregnation conditions are listed in Table 3.

Individual electrode characteristics were studied for their effects on performance. Electrodes of two thicknesses were tested. Table 4 reports the thickness, loading level, utilization, and energy density for electrodes #46 and #48 (0.64 mm thick) and electrodes #41, #53, and #38 (1.0 mm thick). Electrodes with porosities ranging from 60% to 80% were examined. Table 5 compares the effects of porosity on loading level, utilization, and energy density. The resistivity of the electrode also affected electrode performance as shown in Figure 7. A graph of percent utilization versus resistivity is presented.

Impregnation trials were made in a pure water solution containing 2.0 M nickel nitrate, 0.1 M cobalt nitrate and 3.0 M sodium nitrate. The results are listed in Table 6. Electrodes impregnated in aqueous solution performed poorly. Utilization was only 75.5 percent for electrode #23 and 62 percent for #52, respectively, corresponding to energy densities of only 116 Ah/Kg and 88.5 Ah/Kg. These results may be compared with those of Tables 4 and 5 for ethanol based impregnations, where utilizations exceeding 100 percent were common under similar test conditions. The presence of ethanol in the impregnating bath serves several purposes: it reduces the nickel nitrate solution surface tension, allowing easier penetration into the composite plaque; it acts as a buffer in helping to stabilize the pH within the pore structure.

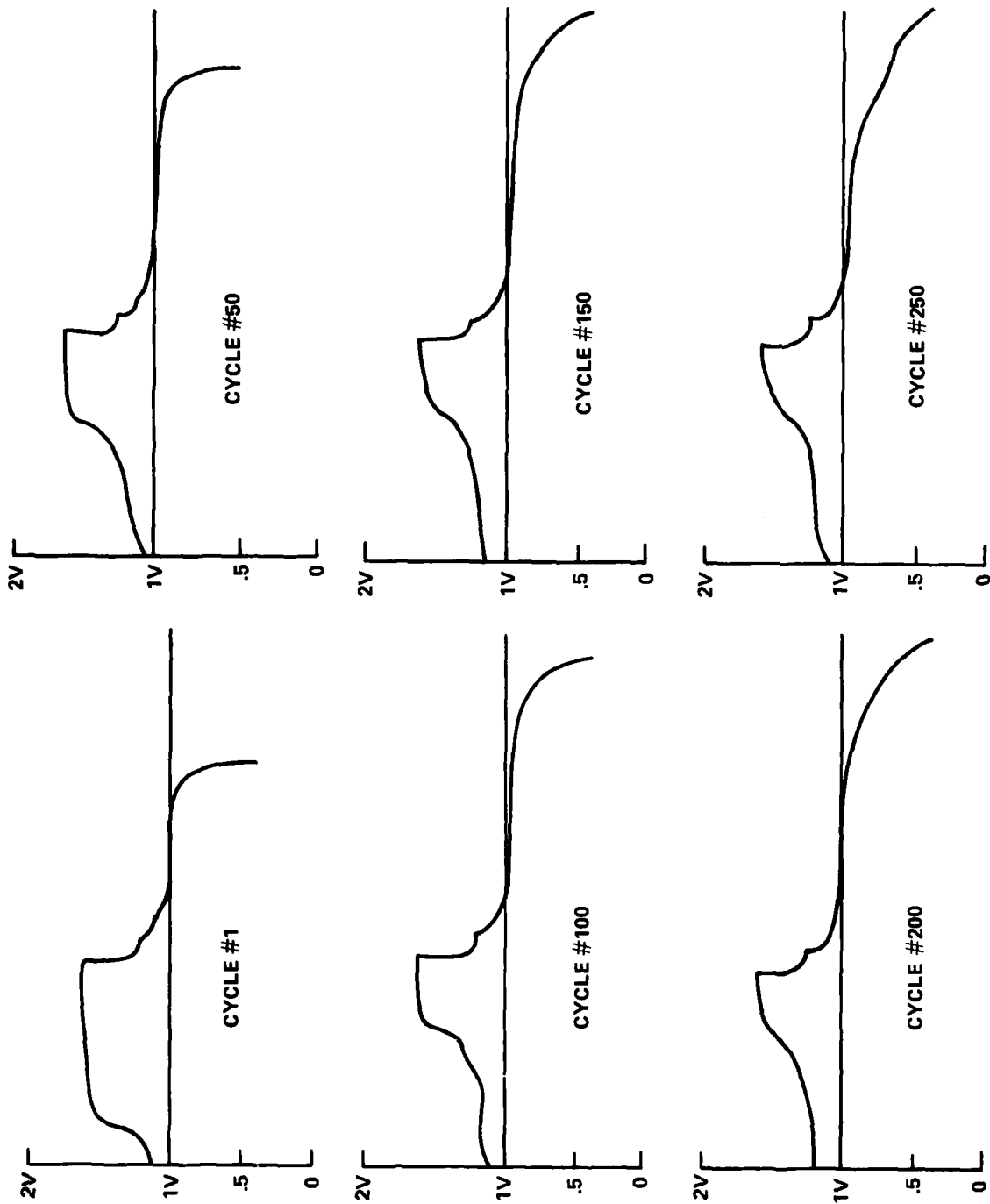


FIGURE 4. CYCLING TEST DATA, ELECTRODE #41

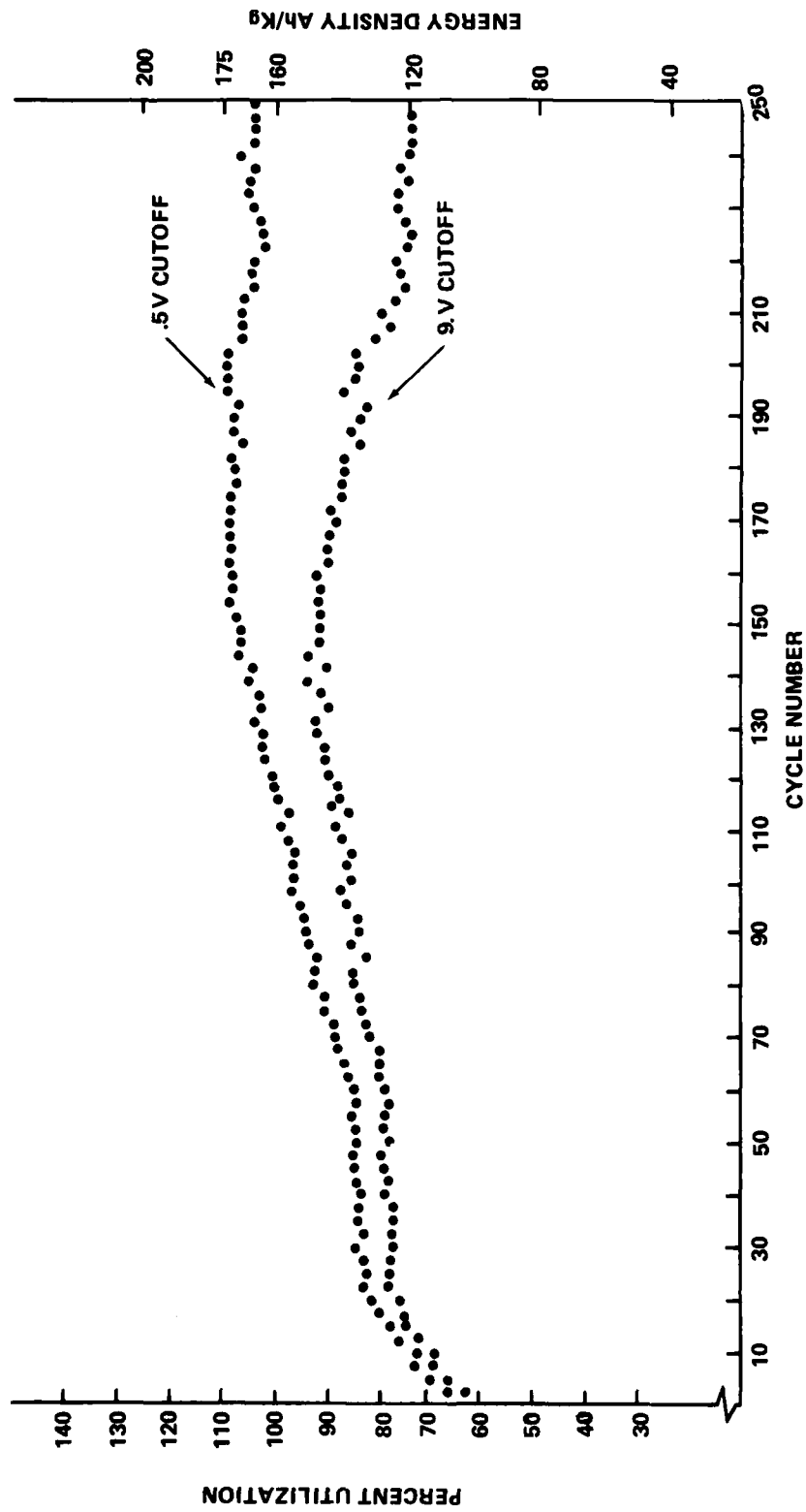


FIGURE 5. UTILIZATION VERSUS CYCLE NUMBER, ELECTRODE #41

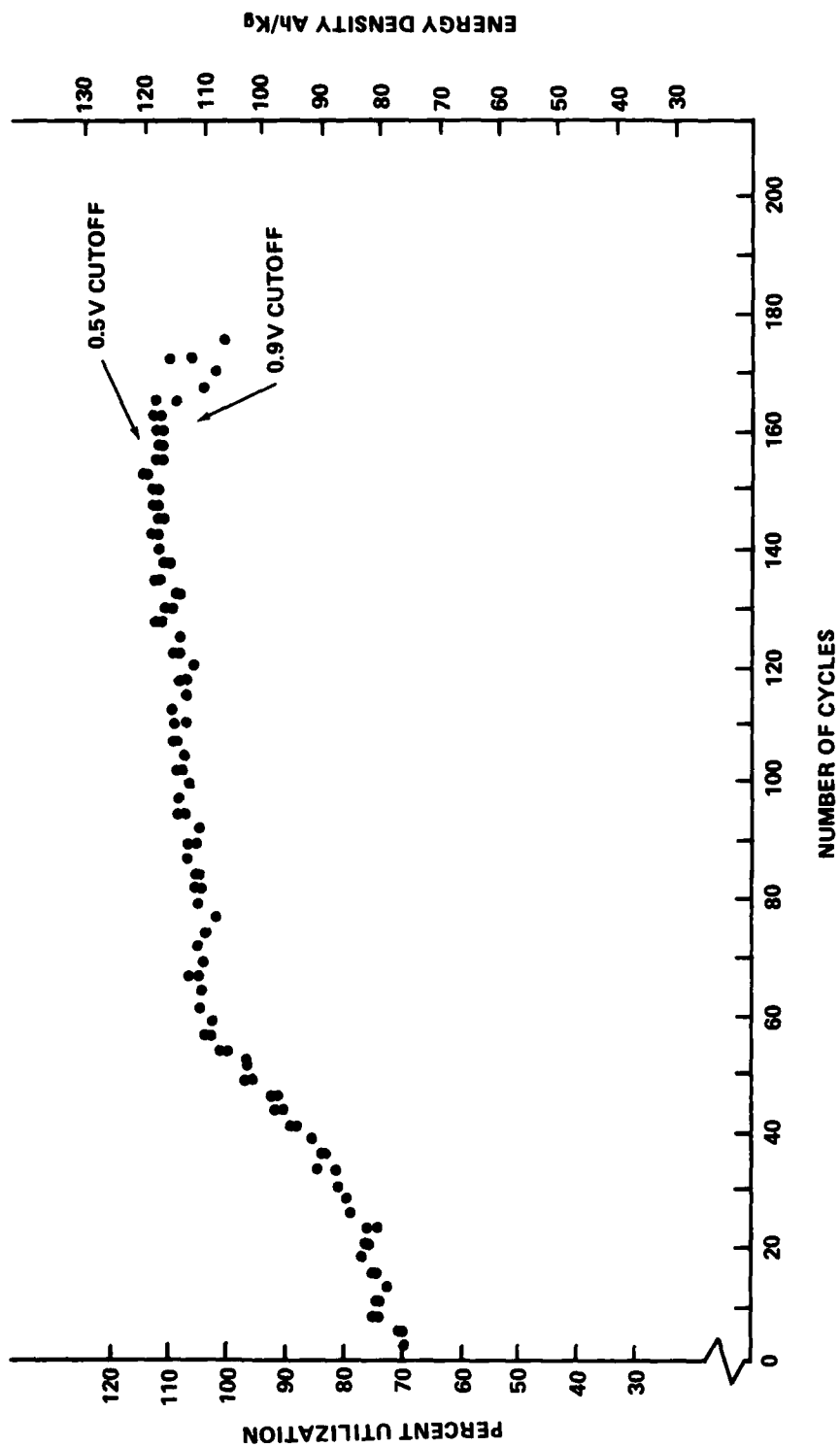


FIGURE 6. UTILIZATION VERSUS CYCLE NUMBER, ELECTRODE #46

TABLE 3. TEST ELECTRODE PARAMETER SUMMARY

| ELECTRODE # | POROSITY % | THICKNESS CM | RESISTIVITY $\mu \cdot \Omega \cdot \text{CM}$ | IMPREGNATION CURRENT FREQUENCY | IMPREGNATION CURRENT AMPS. | LOADING LEVEL g/cc VOID | ACTIVE MATERIAL UTILIZATION % | ENERGY DENSITY Ah/Kg |
|-------------|------------|--------------|--|--------------------------------|----------------------------|-------------------------|-------------------------------|----------------------|
| 22          | 81.9       | 0.108        | 1157.3   | DC                             | 1.8                        | 1.06                    | —                             | —                    |
| 23          | 83.1       | 0.106        | 1009.6   | AQUEOUS SOLN. DC               | 1.8                        | 1.22 *                  | 72.5                          | 116.0                |
| 31          | 81.8       | 0.107        | 1091.5   | 10 PULSES/SEC                  | 0.9                        | 1.37 *                  | 79.4                          | 128.3                |
| 35          | 83.3       | 0.103        | 1074.4   | .33 PULSES/SEC                 | 1.8                        | 1.09                    | 43.8                          | 64.1                 |
| 37          | 81.7       | 0.121        | 1274.6   | DC                             | 3.3                        | 1.61                    | 73.0                          | 126.7                |
| 38          | 81.6       | 0.119        | 1219.9   | DC                             | 1.8                        | 1.43 *                  | 100                           | 170.0                |
| 40          | 81.5       | 0.112        | 843.2  | DC                             | 1.8                        | 0.796                   | 63.1                          | 72.4                 |
| 41          | 81.4       | 0.109        | 954.2  | DC                             | 1.8                        | 1.37                    | 108.5                         | 173.9                |
| 42          | 81.9       | 0.110        | 1397.8   | DC                             | 1.8                        | 0.798                   | 82.0                          | 76.5                 |
| 43          | 77.6       | 0.106        | 1038.3   | REPEATED IMPREG. DC            | 1.8                        | 1.53                    | 78.1                          | 121.9                |
| 44          | 78.4       | 0.109        | 1066.4   | 10 PULSES/SEC                  | 1.8                        | 1.12                    | 70.0                          | 97.1                 |
| 45          | 78.2       | 0.108        | 878.4  | DC                             | 0.9                        | 0.877                   | 23.1                          | 36.1                 |
| 46          | 77.2       | 0.062        | 710.4  | DC                             | 1.8                        | 1.16 *                  | 116.3                         | 123.1                |
| 47          | 75.0       | 0.054        | 532.1  | DC                             | 1.8                        | 1.50 *                  | 96                            | 108.7                |
| 48          | 64.3       | 0.066        | 540.3  | DC                             | 1.8                        | 1.208                   | 121.5                         | 110.6                |
| 52          | 80.8       | 0.107        | 677.6  | AQUEOUS SOLN. DC               | 2.4                        | 1.33 *                  | 62.0                          | 88.5                 |
| 53          | 80.6       | 0.106        | 749.9  | DC                             | 1.8                        | 1.24 *                  | 100.8                         | 145.3                |

\*LONG FORMATION PROCESS

TABLE 4. EFFECT OF ELECTRODE THICKNESS ON PERFORMANCE

| Electrode No. | Thickness cm. | Loading Level g/cc Void | Utilization % | Energy Density Ah/Kg |
|---------------|---------------|-------------------------|---------------|----------------------|
| 48            | 0.006         | 1.208                   | 121.5         | 110.6                |
| 46            | 0.062         | 1.18                    | 116.3         | 123.1                |
| 41            | 0.109         | 1.37                    | 109.5         | 173.9                |
| 53            | 0.106         | 1.24                    | 100.0         | 145.3                |
| 38            | 0.119         | 1.43                    | 100.0         | 170.0                |

TABLE 5. EFFECT OF POROSITY ON ELECTRODE PERFORMANCE

| Electrode No. | Porosity % | Loading Level g/cc Void | Utilization % | Energy Density Ah/Kg |
|---------------|------------|-------------------------|---------------|----------------------|
| 48            | 64.3       | 1.208                   | 121.5         | 110.6                |
| 46            | 77.2       | 1.18                    | 116.3         | 123.0                |
| 41            | 81.4       | 1.37                    | 109.5         | 173.9                |
| 38            | 81.6       | 1.43                    | 100.0         | 170.0                |

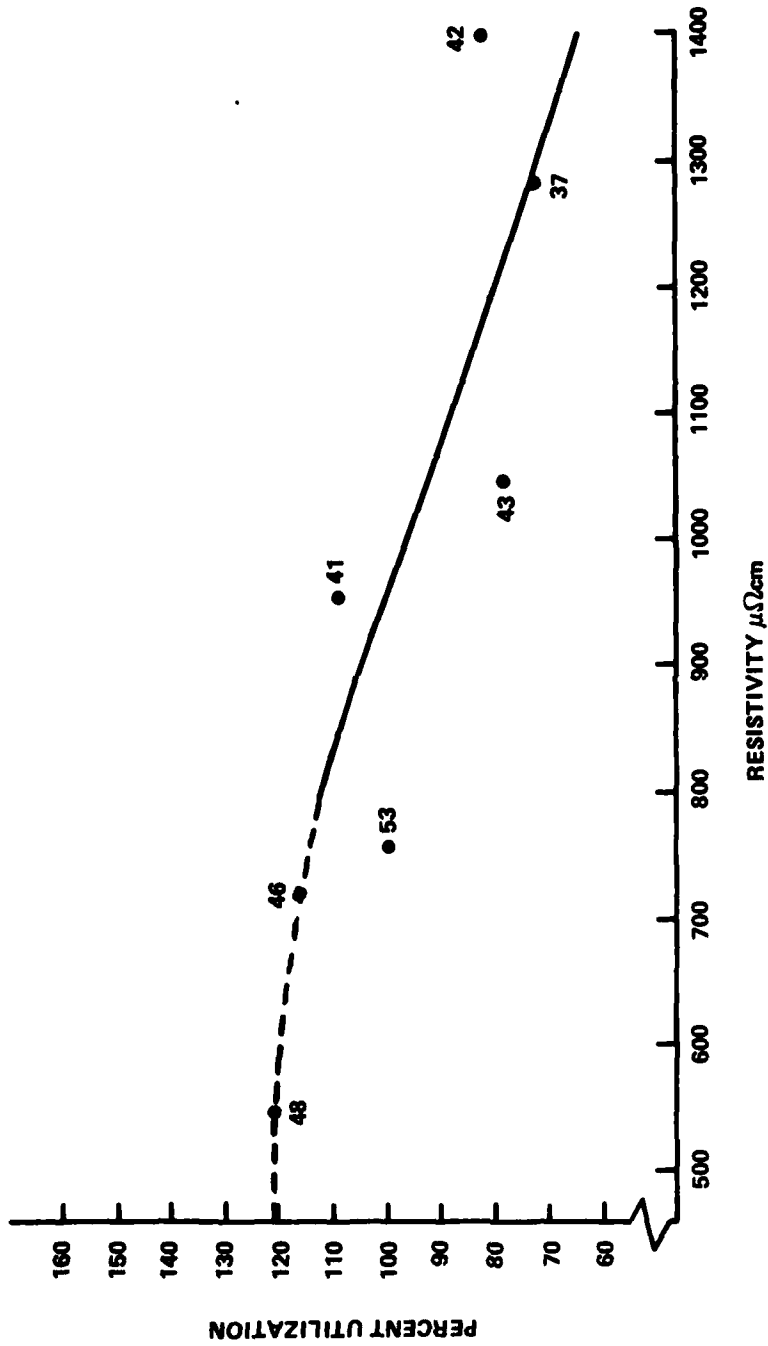


FIGURE 7. UTILIZATION VERSUS PLAQUE RESISTIVITY

TABLE 6. AQUEOUS SOLUTION RESULTS

| Electrode<br>No. | Porosity<br>% | Thickness<br>cm. | Loading Level<br>g/cc Void | Utilization<br>% | Energy Density<br>Ah/Kg |
|------------------|---------------|------------------|----------------------------|------------------|-------------------------|
| 23               | 83.2          | 0.106            | 1.22                       | 72.5             | 116.0                   |
| 52               | 80.8          | 0.107            | 1.33                       | 62.0             | 88.5                    |

## DISCUSSION

The optimal impregnating conditions of current frequency, current density and loading level were studied. The current frequencies ranged from constant pulse (direct current) to 10 pulses/second. It has been suggested<sup>6</sup> that long duration pulses may increase the loading capacity by allowing a replenishing of the nickel ion concentration in the solution within the pores during the "off" period. Such pulses of 5 to 10 minutes duration were not included in this impregnation study. This condition will be tested in future work for comparison of results with those of constant current impregnation.

Figure 3, a three dimensional graph of the impregnated conditions plotted according to the Box Behnken Plan, does not fully satisfy the middle of the edge points prescribed by the Plan. The Box Behnken Plan assumes only three independent variables, but throughout the test it became apparent that there were numerous parameters affecting the impregnation. It was difficult to hold all other parameters constant while testing for only three. Since the electrode plaques were manufactured on a laboratory bench scale, it was difficult for all electrodes to be made uniformly. Also, the loading level of 1.0, 1.5, and 2.0 grams were not exactly achievable as predicted from theoretical calculations. In spite of the experimental difficulties, there appears to be a direct relationship between theoretical and experimental results. From the Box Behnken Plan test, delineations could be drawn indicating the best conditions for impregnation. These conditions are presented in the Conclusions.

Interpretation of Cycling Data

Figure 8 contains schematic representations of charge/discharge curves for the nickel-cadmium electrode couple. Information on electrode efficiency can be obtained by examining these curve shapes. The top picture in Figure 8(a) represents the nickel charging cycle. The charging takes place with a monotonic increase in potential. The cadmium charge cycle, 8(b), shows that a sharp rise in potential occurs as the electrode reaches full charge. The addition of both nickel and cadmium charge cycles results in the cycle as shown in Figure 8(c). Region A represents overpotential, the rise in potential required to sustain charging. Region B, the plateau region, is the actual charging of the cell. The exhaustion, Region C, occurs as charging is completed. The rise in

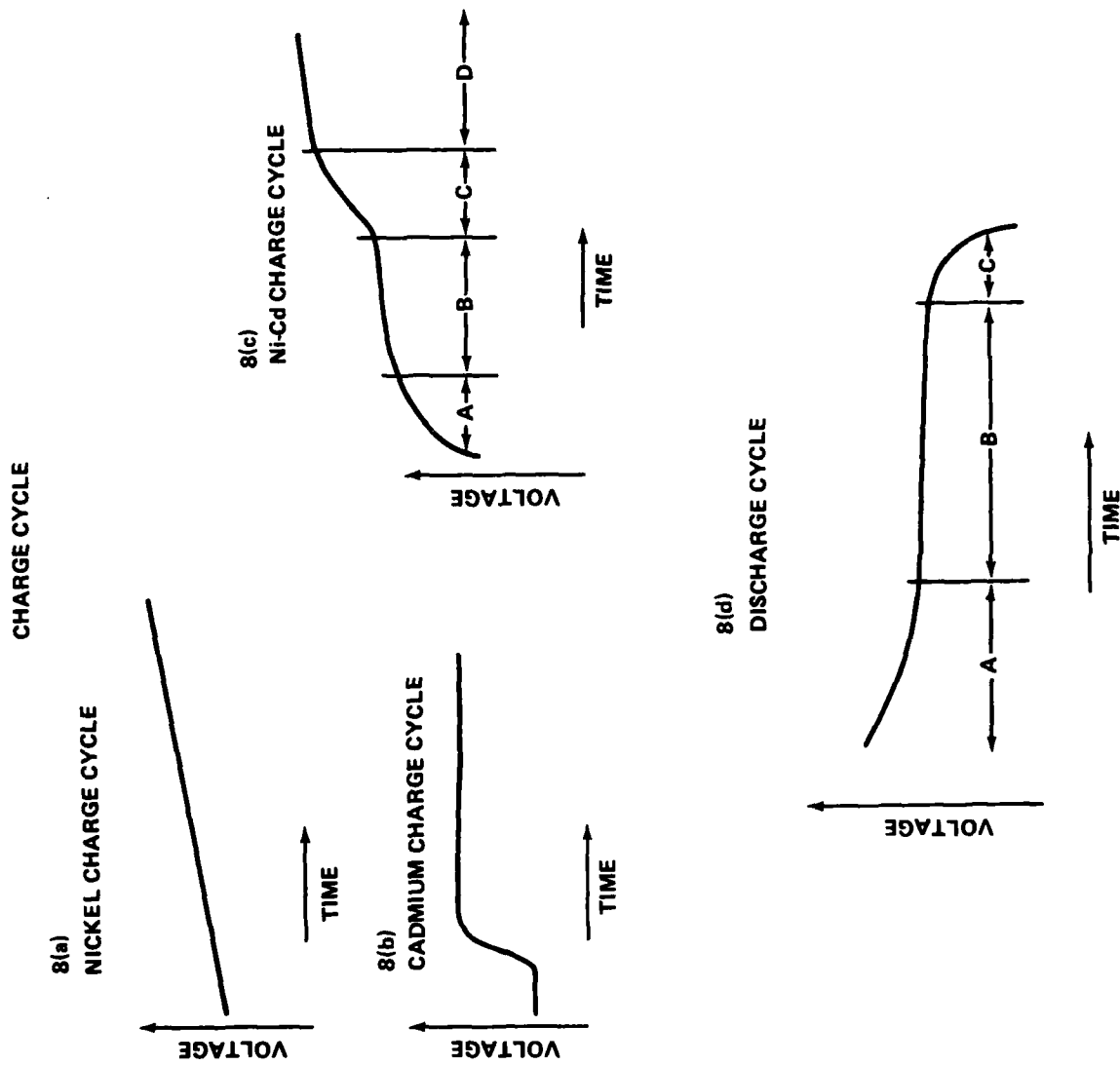


FIGURE 8. CHARGE-DISCHARGE POTENTIAL PROFILES

potential indicates an increase in resistivity as the active material becomes fully charged. Region D is known as overcharge; oxidation is occurring at the electrode. The discharge of a Ni-Cd battery is portrayed in the lower half of the figure. Region A displays a decrease in potential due to a change in the concentration of the active material. The steady state Region B represents the cell discharging. Region C, the knee of the curve, is the exhaustion region. This drop in overpotential is due to the decrease of reactant from charged to discharged state. If the drop is sharp, the change in potential is due to the decrease of available charged material, but if the decrease in potential drop is slow and sloping, then the potential drop occurs because of increasing resistivity.

Actual cycle data for electrode #41 of Figure 4 may be analyzed as an example. The plateau region of the charge cycle becomes progressively longer with cycling. The exhaustion region rises to a steeper slope. The longer plateau region indicates that the nickel electrode is retaining more charge. The sharp rise and short plateau of the exhaustion region represents charge completion in the cadmium electrode, indicating that the nickel and cadmium electrode are quite well matched in capacity. A sharp drop in the potential at the end of the discharge cycle occurs. This is an example of the condition mentioned above where the potential drop is due to decrease in charged active material. The deteriorating potential drop of the discharge exhaustion region with increasing cycle number is evident. A semiconducting layer of unchargeable active material, through which the current must pass, builds up with cycling. This layer increases electrode resistivity, markedly altering the discharge curve shape, especially below 0.9 volts.

#### Life Cycle Utilization Profiles

Figure 5 displays a life cycle utilization profile of electrode #41. This profile is also representative of other electrodes. There are common characteristics of these curves (see also Figure 6). A region of increasing utilization extends for about 30 cycles and then the utilization levels off for another 30 to 40 cycles. At about cycle 70, another region of increasing utilization results followed by a plateau region near 100 percent efficiency.

An attempt was made to eliminate the region of increasing utilization. Based on a suggestion by H. N. Seiger, an extended formation process was used. The initial cathodization period was extended for 2 hours. Results suggested that the long formation process prepared the active material to a similar degree as did the first 50 cycles. Initial utilization was somewhat improved but the entire region of increasing utilization could not be eliminated.

#### Effects of Electrode Characteristics on Impregnation

Thick electrodes (40 mils) were found to attain greater energy densities than thin electrodes. The amount of active material loaded in a thin electrode was limited by the relatively large current collector volume. Conversely, active material and thus greater energy density is realized in thick electrodes due to the presence of a relatively larger sinter body. However, a too thick electrode may encounter problems with unevenly distributed active material and

higher resistivity. High porosity (80 percent) electrodes were determined to be more favorable by the same reasoning. Electrodes too porous (>90 percent) have larger average pore size and decreased electrical conductivity, adversely affecting electrode performance. The resistivity was lowered for electrode #53 by adding strips of current collector diagonally across each side of the grid. But, the added weight of the strips made the electrode plaque heavier. Consequently the gravimetric energy density was reduced.

#### Role of pH

Another factor which greatly affects the impregnation is the pH of the impregnation solution. Higher loading levels were achieved with acidic solutions; however, high acidity (low pH) also promotes corrosive attack of the sinter matrix. It is recommended, therefore, that the pH be maintained around 2.5 with an automatic pH controller. At about pH 5, nickel hydroxide begins to precipitate out of the solution. The active material is no longer available for loading into the plaque. In addition, the precipitate forms a surface buildup which blocks the pores of the electrode. An acidic bulk solution normally insures that the nickel ions reach the interior of the pores, where the  $\text{OH}^-$  is generated, before being deposited as  $\text{Ni}(\text{OH})_2$ . However, as the bulk solution pH approaches 5, appreciable  $\text{OH}^-$  is present outside the plaque surface.  $\text{Ni}(\text{OH})_2$  begins to precipitate in this region. As a result, loading levels are limited in impregnation solutions of high pH.

One method tried in order to increase the loading level was to reimpregnate the electrode after formation. Electrode #43 was reimpregnated four times for 15 minutes each to see if reimpregnation enhanced electrode performance. The loading level reached 1.5 g/cc void while other electrodes impregnated for the same duration of time under single impregnation loaded to lesser levels. The electrode performance of #43 is compared with another electrode (#46) of the same porosity, and another (#41) with the same thickness. The active material utilization as well as energy density was lower in the case of reimpregnated electrodes than for the singly impregnated electrodes. Reimpregnation appears to affect the crystalline structure of the active material. Evidently the form of active material deposited by reimpregnation is not as efficient.

#### Comment on Utilization of Active Material

It is interesting that active material utilizations over 100 percent are achievable. This is possible since the electrochemical equivalent for Nickel is calculated assuming a pure  $\text{Ni}^{2+} \sim \text{Ni}^{3+}$  transition. However,  $\text{Ni}^{4+}$  is also possible. In addition, differences in electrochemical activity due to the presence of cobalt have not been taken into account. The role of the cobalt additive is complex and not thoroughly understood. A study of additives in Nickel electrodes is currently underway at NSWC.

CONCLUSIONS

Performance of the nickel composite electrode is superior to that of commercially available powder sintered electrodes on a gravimetric basis. Ni.C.E. achieves energy densities of 170 Ah/Kg at C/2 discharge rates. The active material utilization approach 100 percent. Commercial powder sinters achieve about 110 Ah/Kg. Volumetric energy densities at present are comparable for NI.C.E. and commercial sinters.

The best impregnation conditions are direct current with a current density of 0.058 amps/cm<sup>2</sup>. The optimal fine black crystalline form of active material was deposited at this current density. Pulsed current was not found to be advantageous at the frequencies employed.

Other parameters affect the performance of the electrode. These include electrode plaque characteristics--thickness, porosity, and resistivity.

Eighty-one percent porosity and 40 mil thickness were the optimal electrode characteristics determined by comparing energy density and utilization. Electrode performance increases with lower resistivity. Methods of reducing resistivity still need to be examined.

Increased loading levels are desirable since they lead to higher energy densities. But loading levels cannot be increased by reimpregnating the electrodes. These show that single impregnation yields best results. Optimum loading can occur if pH of the impregnation solution is maintained near 2.5. pH levels above 5.0 result in markedly reduced active material loading, increased surface deposition and rapid depletion of the impregnation bath.

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